

August 20, 2008

**Concerning price revision of photoresist developer  
for electronics manufacturing**

**Tokuyama Corporation**

Tokuyama Corporation announced that it has made a decision to increase the sales prices of photoresist developer for electronics manufacturing (TMAH: tetramethylammonium hydroxide), effective for shipments from October 1, 2008, and will negotiate with its customers. The range of the price increases is ¥25/L (25 yen per liter) or more. (with reference to a 25% concentration product)

This product is mainly used as developer in the photolithography process of micro-processing for forming sharp wiring patterns, when semiconductor devices and LCD panels are produced. Demand for this product is continuing to increase strongly with the worldwide growth of the information communication industry. However, its profitability is sharply getting worse, due to the steep price hikes of methanol and ammonia as raw materials, cost increases of electricity, steam, and distribution caused by the sharp rise in the prices of coal and crude oil, and other factors. Under such circumstances, determining that it has become difficult for the company to absorb the increased costs of these raw materials and fuels only by the company's rationalization efforts, Tokuyama has decided that it will implement an upward price revision.

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